

Petr Vařina

List of Publications by Year in descending order

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docs citations

81
times ranked

778
citing authors

| # | ARTICLE | IF | CITATIONS |
|----|---|-----|-----------|
| 1 | Single-shot spatial-resolved optical emission spectroscopy of argon and titanium species within the spoke. <i>Journal Physics D: Applied Physics</i> , 2022, 55, 035205. | 2.8 | 2 |
| 2 | Dynamics of bipolar HiPIMS discharges by plasma potential probe measurements. <i>Plasma Sources Science and Technology</i> , 2022, 31, 025007. | 3.1 | 10 |
| 3 | W 4f electron binding energies in amorphous W-B-C systems. <i>Applied Surface Science</i> , 2022, 586, 152824. | 6.1 | 4 |
| 4 | Predicting the composition of W-B-C coatings sputtered from industrial cylindrical segmented target. <i>Surface and Coatings Technology</i> , 2022, 438, 128411. | 4.8 | 3 |
| 5 | Spatially resolved study of spokes in reactive HiPIMS discharge. <i>Plasma Sources Science and Technology</i> , 2022, 31, 055010. | 3.1 | 2 |
| 6 | Spoke behaviour in reactive HiPIMS. <i>Plasma Sources Science and Technology</i> , 2021, 30, 055016. | 3.1 | 4 |
| 7 | Enhancing mechanical properties and cutting performance of industrially sputtered AlCrN coatings by inducing cathodic arc glow discharge. <i>Surface and Coatings Technology</i> , 2021, 422, 127563. | 4.8 | 9 |
| 8 | Microstructure of titanium coatings controlled by pulse sequence in multipulse HiPIMS. <i>Surface and Coatings Technology</i> , 2021, 423, 127624. | 4.8 | 7 |
| 9 | Al ₂ O ₃ -Ta ₂ O ₅ multilayer thin films deposited by pulsed direct current magnetron sputtering for dielectric applications. , 2021, , . | | 0 |
| 10 | MAGNETRON SPUTTERING DEPOSITION OF HIGH ENTROPY NITRIDES FROM ChRromium-HaFniium-MOlybdenum-TAntalum-Wolfram SYSTEM. , 2021, , . | | 0 |
| 11 | INDUSTRIAL MAGNETRON SPUTTERING OF ZrN/Cu NANOSTRUCTURED COATINGS FOR ANTI-BACTERIAL PURPOSES. , 2021, , . | | 0 |
| 12 | Adhesion and dynamic impact wear of nanocomposite TiC-based coatings prepared by DCMS and HiPIMS. <i>International Journal of Refractory Metals and Hard Materials</i> , 2020, 86, 105123. | 3.8 | 17 |
| 13 | The effect of chemical composition on the structure, chemistry and mechanical properties of magnetron sputtered W-B-C coatings: Modeling and experiments. <i>Surface and Coatings Technology</i> , 2020, 383, 125274. | 4.8 | 16 |
| 14 | A transition from petal-state to lotus-state in AZ91 magnesium surface by tailoring the microstructure. <i>Surface and Coatings Technology</i> , 2020, 383, 125239. | 4.8 | 11 |
| 15 | Influence of sputtered species ionisation on the hysteresis behaviour of reactive HiPIMS with oxygen admixture. <i>Plasma Sources Science and Technology</i> , 2020, 29, 025027. | 3.1 | 12 |
| 16 | The Effect of a Taper Angle on Micro-Compression Testing of Mo-B-C Coatings. <i>Materials</i> , 2020, 13, 3054. | 2.9 | 5 |
| 17 | DYNAMIC IMPACT WEAR AND IMPACT RESISTANCE OF W-B-C COATINGS. <i>Acta Polytechnica CTU Proceedings</i> , 2020, 27, 37-41. | 0.3 | 0 |
| 18 | Revisiting particle dynamics in HiPIMS discharges. I. General effects. <i>Journal of Applied Physics</i> , 2020, 128, . | 2.5 | 18 |

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|----|--|-----|-----------|
| 19 | Revisiting particle dynamics in HiPIMS discharges. II. Plasma pulse effects. Journal of Applied Physics, 2020, 128, . | 2.5 | 14 |
| 20 | Composition, Structure and Mechanical Properties of Industrially Sputtered Taâ€“Bâ€“C Coatings. Coatings, 2020, 10, 853. | 2.6 | 5 |
| 21 | Effect of substrate bias voltage on the composition, microstructure and mechanical properties of W-B-C coatings. Applied Surface Science, 2020, 528, 146966. | 6.1 | 19 |
| 22 | Ionisation fractions of sputtered titanium species at target and substrate region in HiPIMS. Plasma Sources Science and Technology, 2020, 29, 055010. | 3.1 | 18 |
| 23 | Study of the transition from self-organised to homogeneous plasma distribution in chromium HiPIMS discharge. Journal Physics D: Applied Physics, 2020, 53, 155201. | 2.8 | 13 |
| 24 | On the origin of multilayered structure of W-B-C coatings prepared by non-reactive magnetron sputtering from a single segmented target. Surface and Coatings Technology, 2019, 377, 124864. | 4.8 | 8 |
| 25 | Optical Characterization of Non-Stoichiometric Silicon Nitride Films Exhibiting Combined Defects. Coatings, 2019, 9, 416. | 2.6 | 13 |
| 26 | Optical characterization of inhomogeneous thin films containing transition layers using the combined method of spectroscopic ellipsometry and spectroscopic reflectometry based on multiple-beam interference model. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2019, 37, . | 1.2 | 8 |
| 27 | Study of W-B-C thin films prepared by magnetron sputtering using a combinatorial approach. International Journal of Refractory Metals and Hard Materials, 2019, 85, 105066. | 3.8 | 8 |
| 28 | Evolution of discharge parameters and sputtered species ionization in reactive HiPIMS with oxygen, nitrogen and acetylene. Plasma Sources Science and Technology, 2019, 28, 025011. | 3.1 | 9 |
| 29 | Microstructural changes of amorphous Moâ€“Bâ€“C coatings upon thermal annealing. Surface and Coatings Technology, 2019, 379, 125052. | 4.8 | 7 |
| 30 | The statistics of spoke configurations in high-power impulse magnetron sputtering discharges. Journal Physics D: Applied Physics, 2019, 52, 125201. | 2.8 | 7 |
| 31 | The tribological properties of short range ordered W-B-C protective coatings prepared by pulsed magnetron sputtering. Surface and Coatings Technology, 2019, 357, 364-371. | 4.8 | 18 |
| 32 | Approximate methods for the optical characterization of inhomogeneous thin films: Applications to silicon nitride films. Journal of Electrical Engineering, 2019, 70, 16-26. | 0.7 | 4 |
| 33 | Evolution of structure and mechanical properties of hard yet fracture resistant Wâ€“Bâ€“C coatings with varying C/W ratio. Surface and Coatings Technology, 2018, 340, 103-111. | 4.8 | 22 |
| 34 | Effect of magnetic field on spoke behaviour in HiPIMS plasma. Journal Physics D: Applied Physics, 2018, 51, 095204. | 2.8 | 28 |
| 35 | Use of the Richardson extrapolation in optics of inhomogeneous layers: Application to optical characterization. Surface and Interface Analysis, 2018, 50, 757-765. | 1.8 | 15 |
| 36 | Fracture Resistance Enhancement in Hard Mo-B-C Coatings Tailored by Composition and Microstructure. Journal of Nanomaterials, 2018, 2018, 1-7. | 2.7 | 11 |

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|----|---|-----|-----------|
| 37 | Superhard nanocomposite nc-TiC/a-C:H coatings: The effect of HiPIMS on coating microstructure and mechanical properties. <i>Surface and Coatings Technology</i> , 2017, 311, 257-267. | 4.8 | 52 |
| 38 | On the significance of running-in of hard nc-TiC/a-C:H coating for short-term repeating machining. <i>Surface and Coatings Technology</i> , 2017, 315, 17-23. | 4.8 | 3 |
| 39 | Cathode voltage and discharge current oscillations in HiPIMS. <i>Plasma Sources Science and Technology</i> , 2017, 26, 055015. | 3.1 | 11 |
| 40 | Simultaneous electrical and optical study of spoke rotation, merging and splitting in HiPIMS plasma. <i>Journal Physics D: Applied Physics</i> , 2017, 50, 015209. | 2.8 | 14 |
| 41 | Thermal stability of hard nanocomposite Mo-B-C coatings. <i>Vacuum</i> , 2017, 138, 199-204. | 3.5 | 18 |
| 42 | On the effect of the substrate to target position on the properties of titanium carbide/carbon coatings. <i>Surface and Coatings Technology</i> , 2017, 328, 462-468. | 4.8 | 9 |
| 43 | Ti atom and Ti ion number density evolution in standard and multi-pulse HiPIMS. <i>Journal Physics D: Applied Physics</i> , 2017, 50, 365202. | 2.8 | 22 |
| 44 | Investigation of the Influence of Ni Doping on the Structure and Hardness of Ti-Ni-C Coatings. <i>Journal of Nanomaterials</i> , 2017, 2017, 1-13. | 2.7 | 3 |
| 45 | On the study of the mechanical properties of Mo-B-C coatings. <i>EPJ Applied Physics</i> , 2016, 75, 24716. | 0.7 | 17 |
| 46 | Principles and practice of an automatic process control for the deposition of hard nc-TiC/a-C:H coatings by hybrid PVD-PECVD under industrial conditions. <i>Surface and Coatings Technology</i> , 2016, 304, 9-15. | 4.8 | 7 |
| 47 | Determination of titanium atom and ion densities in sputter deposition plasmas by optical emission spectroscopy. <i>Plasma Sources Science and Technology</i> , 2015, 24, 065022. | 3.1 | 18 |
| 48 | Comparative analysis of thermal stability of two different nc-TiC/a-C:H coatings. <i>Surface and Coatings Technology</i> , 2015, 267, 32-39. | 4.8 | 6 |
| 49 | Study of the thermal dependence of mechanical properties, chemical composition and structure of nanocomposite TiC/a-C:H coatings. <i>Surface and Coatings Technology</i> , 2014, 242, 62-67. | 4.8 | 9 |
| 50 | Reprint of "Study of the thermal dependence of mechanical properties, chemical composition and structure of nanocomposite TiC/a-C:H coatings". <i>Surface and Coatings Technology</i> , 2014, 255, 158-163. | 4.8 | 0 |
| 51 | On the control of deposition process for enhanced mechanical properties of nc-TiC/a-C:H coatings with DC magnetron sputtering at low or high ion flux. <i>Surface and Coatings Technology</i> , 2014, 255, 8-14. | 4.8 | 18 |
| 52 | Tribological properties of nc-TiC/a-C:H coatings prepared by magnetron sputtering at low and high ion bombardment of the growing film. <i>Surface and Coatings Technology</i> , 2014, 241, 64-73. | 4.8 | 12 |
| 53 | Understanding of hybrid PVD-PECVD process with the aim of growing hard nc-TiC/a-C:H coatings using industrial devices with a rotating cylindrical magnetron. <i>Surface and Coatings Technology</i> , 2014, 255, 118-123. | 4.8 | 6 |
| 54 | Titanium carbide/carbon nanocomposite hard coatings: A comparative study between various chemical analysis tools. <i>Surface and Coatings Technology</i> , 2014, 256, 41-46. | 4.8 | 12 |

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|----|--|-----|-----------|
| 55 | Non-monotonous evolution of hybrid PVDâ€“PECVD process characteristics on hydrocarbon supply. Surface and Coatings Technology, 2013, 232, 283-289. | 4.8 | 18 |
| 56 | Laser desorption ionisation quadrupole ion trap timeâ€“ofâ€“flight mass spectrometry of titaniumâ€“carbon thin films. Rapid Communications in Mass Spectrometry, 2013, 27, 1196-1202. | 1.5 | 8 |
| 57 | Evaluation of composition, mechanical properties and structure of nc-TiC/a-C:H coatings prepared by balanced magnetron sputtering. Surface and Coatings Technology, 2012, 211, 111-116. | 4.8 | 27 |
| 58 | Characterization of a periodic instability in filamentary surface wave discharge at atmospheric pressure in argon. Journal Physics D: Applied Physics, 2012, 45, 055201. | 2.8 | 25 |
| 59 | Air DCSBD plasma treatment of Al surface at atmospheric pressure. Surface and Coatings Technology, 2012, 206, 3011-3016. | 4.8 | 34 |
| 60 | Depth profile analyses of nc-TiC/a-C:H coating prepared by balanced magnetron sputtering. Surface and Coatings Technology, 2011, 205, S53-S56. | 4.8 | 16 |
| 61 | Study of hybrid PVDâ€“PECVD process of Ti sputtering in argon and acetylene. Surface and Coatings Technology, 2011, 205, S299-S302. | 4.8 | 14 |
| 62 | Complex analysis of SiO _x C _y H _z films deposited by an atmospheric pressure dielectric barrier discharge. Surface and Coatings Technology, 2011, 205, S330-S334. | 4.8 | 15 |
| 63 | Visualization of Revolving Modes in RF and MW Nonthermal Atmospheric Pressure Plasma Jets. IEEE Transactions on Plasma Science, 2011, 39, 2350-2351. | 1.3 | 8 |
| 64 | Plasma diagnostics using electron paramagnetic resonance. Journal Physics D: Applied Physics, 2010, 43, 124020. | 2.8 | 4 |
| 65 | Monitoring of PVD, PECVD and etching plasmas using Fourier components of RF voltage. Plasma Physics and Controlled Fusion, 2010, 52, 124011. | 2.1 | 3 |
| 66 | Monitoring of magnetron target poisoning by measurement of higher harmonics of discharge voltages. Plasma Sources Science and Technology, 2010, 19, 055016. | 3.1 | 3 |
| 67 | On the oxygen addition into nitrogen post-discharges. Journal Physics D: Applied Physics, 2009, 42, 075202. | 2.8 | 19 |
| 68 | Modelling of the reactive sputtering process with non-uniform discharge current density and different temperature conditions. Plasma Sources Science and Technology, 2009, 18, 025011. | 3.1 | 9 |
| 69 | Harmonic analysis of discharge voltages as a tool to control the RF sputtering deposition process. Europhysics Letters, 2009, 85, 15002. | 2.0 | 10 |
| 70 | Study of a fast high power pulsed magnetron discharge: role of plasma deconfinement on the charged particle transport. Plasma Sources Science and Technology, 2008, 17, 035007. | 3.1 | 26 |
| 71 | Self-consistent spatio-temporal simulation of pulsed microwave discharge. Journal Physics D: Applied Physics, 2008, 41, 015210. | 2.8 | 8 |
| 72 | Experimental study of a pre-ionized high power pulsed magnetron discharge. Plasma Sources Science and Technology, 2007, 16, 501-510. | 3.1 | 58 |

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|----|---|-----|-----------|
| 73 | Analysis of the Transport of Ionized Titanium Atoms in a Highly Ionized Sputter Deposition Process. Plasma Processes and Polymers, 2007, 4, S424-S429. | 3.0 | 15 |
| 74 | Dissociation increase due to admixtures. European Physical Journal D, 2006, 56, B877-B881. | 0.4 | 3 |
| 75 | An experimental study of high power microwave pulsed discharge in nitrogen. Plasma Sources Science and Technology, 2006, 15, 574-581. | 3.1 | 10 |
| 76 | Theoretical study of pulsed microwave discharge in nitrogen. Plasma Sources Science and Technology, 2005, 14, 751-756. | 3.1 | 30 |
| 77 | Spatial characterization of an IPVD reactor: neutral gas temperature and interpretation of optical spectroscopy measurements. Plasma Sources Science and Technology, 2005, 14, 321-328. | 3.1 | 19 |
| 78 | Reduction of transient regime in fast preionized high-power pulsed-magnetron discharge. Europhysics Letters, 2005, 72, 390-395. | 2.0 | 37 |
| 79 | Electron density measurements in afterglow of high power pulsed microwave discharge. Plasma Sources Science and Technology, 2004, 13, 562-568. | 3.1 | 15 |
| 80 | Simultaneous measurement of N and O densities in plasma afterglow by means of NO titration. Plasma Sources Science and Technology, 2004, 13, 668-674. | 3.1 | 25 |
| 81 | Temporal studies of titanium ionised density fraction in reactive HIPIMS with nitrogen admixture. Plasma Sources Science and Technology, 0, , . | 3.1 | 3 |